# DAMAGE AT THE INTERFACE BETWEEN NANOTWINNED AND DE-NANOTWINNED REGIONS IN FATIGUED NANOTWINNED Cu

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#### **OUTLINE**

**BACKGROUND: Mostly nanocrystalline Cu** 

**NANOTWINNED Cu: Description** 

#### **FATIGUE:**

Effect of fatigue on nanotwinned Cu Structural and Strength Changes Crack Formation & Interfacial damage FIRST "PRACTICAL" METHOD OF MAKING NANOCRYSTALLINE SAMPLES, AND THEIR FIRST PROPERTY MEASUREMENTS, WERE ANNOUNCED BY H. GLEITER AT AN ANNUAL RISØ CONFERENCE IN THE 1980s

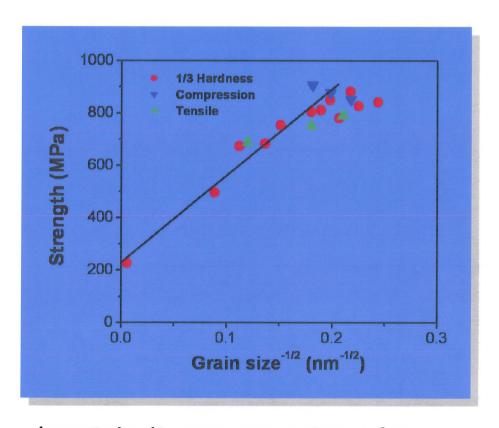
A FRENZY OF RESEARCH IN THE AREA FOLLOWED

("NANOCRYSTALLINE" MEANS GRAIN SIZE ~ < 100 nm)

## WHY THE GREAT INTEREST IN NANOSTRUCTURED METALS?

- > HALL-PETCH PREDICTION  $\sigma_{y} = \sigma_{o} + k/Vd$
- > NEW DEFORMATION MECHANISMS
  MUST COME INTO PLAY

## Hall-Petch Behavior of Various Nanocrystalline Cu Samples

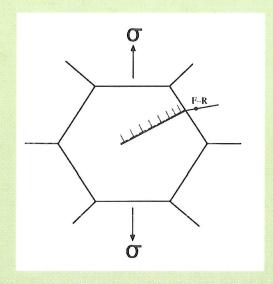


(straight line = extension of coarsegrain data)

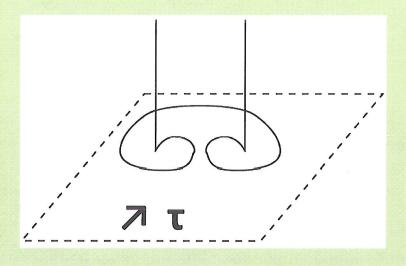
 Summary of different synthesis routes (ballmilling, surface attrition, & IGC) and measurement methods (compression, tension, & hardness)

#### Mechanisms For Plastic Deformation

#### **Coarse-Grain Concepts**



Cottrell
Hall-Petch Equation



Frank-Read Source

To activate F-R source, shear stress T ~ 2Gb/d

## Contributions of Molecular Dynamics Simulations

- Reveals deformation processes on an atomic scale
- Shows behavior at very small grain sizes (<</li>
   ~10 nm), where synthesis is difficult
- Computer samples are free from flaws that mask intrinsic behavior in experiments

A major finding: Dislocations are emitted from & absorbed into grain boundaries (even at small grain sizes!)

### EXTENSIVE GB ENERGY IN NANO METALS PROMOTES MICROSTRUCTURAL INSTABILITY

\* SYNTHESIS METHODS FOR NANO METALS INVOLVE A "DRIVEN" TECHNIQUE (SCHUH)

\*SPONTANEOUS GRAIN GROWTH SEEN AT RT IN HIGH PURITY NANO METALS†

†Günther, Kumpmann and Kunze, 1992 Weissmüller, Löffler and Kelber, 1995

## OBVIOUSLY, NANOCRYSTALLINE METALS HAVE PROBLEMS!

STRUCTURAL INSTABILITY
EXTREMELY BRITTLE
LOW ELECTRICAL CONDUCTIVITY

### NANO-TWINNED METALS, INTERESTING MICROSTRUCTURES

- HIGH STRENGTH\*, ASSOCIATED WITH SPACING BETWEEN TWIN BOUNDARIES
- HIGHER DUCTILITY THAN EQUIVALENT 3-D
- GOOD STRUCTURAL STABILITY AT HIGH T\*\*
- HIGH ELECTRICAL CONDUCTIVITY\*

#### **UNDER CYCLIC (AND OTHER) STRESSES?**

\* Lu, Chen, Huang, Lu, Science 323 (2009) 607

\*\* Anderoglu, Misra, Wang, Zhang, JAP (2008) 094322

### A SPECIAL NANO-TWINNED MICROSTRUCTURE: COLUMNS OF ALIGNED TWINS



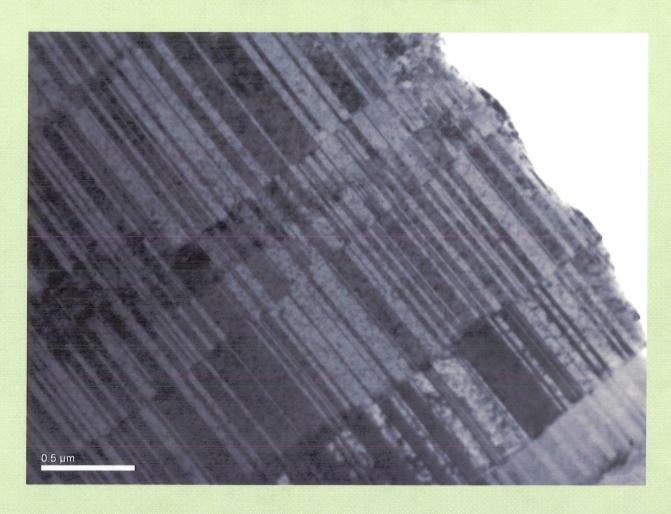
#### PROCESSED USING NANOLAMINATE TECHNOLOGY

- Foils coated on standard silicon wafers by DC magnetron sputtering
- Foil thickness = 170  $\mu$ m, self-supporting
- Ultrahigh purity Cu targets, argon gas
- (Hodge, Wang and Barbee, MatsSciEngA 2006)

#### MODES OF DEFORMATION STUDIED

- TENSION-TENSION FATIGUE, DOGBONE SAMPLES
- COMPRESSION-COMPRESSION FATIGUE, DISKS
- EXTREME COMPRESSION, DISKS
- INDENTATION, COMPLEX STRESS STATE
- HIGH PRESSURE TORSION (HPT)
- TRANSVERSE SECTIONS STUDIED BY FIB + TEM

## NANOTWINNED Cu, AS RECEIVED TEM IMAGE



#### Max Stress = 450 MPa,5195 Cycles



**TENSION-TENSION FATIGUE** 

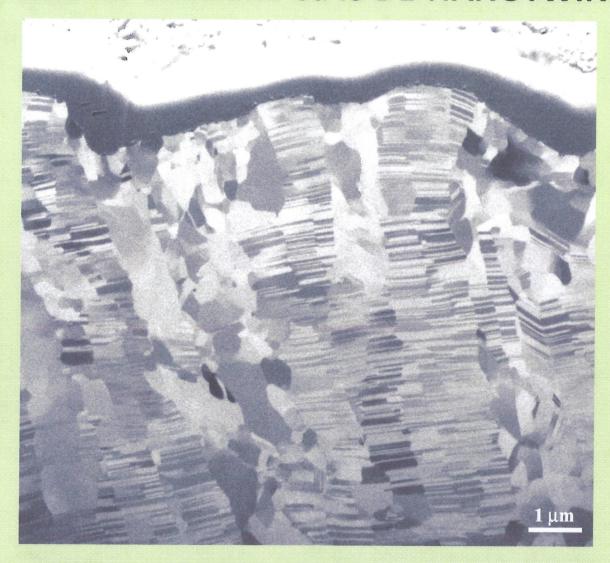
#### **TEM IMAGE**

NOTE
DISLOCATIONS
BETWEEN
ADJACENT
TWIN
BOUNDARIES

Fatigued to failure at 450 MPa max stress

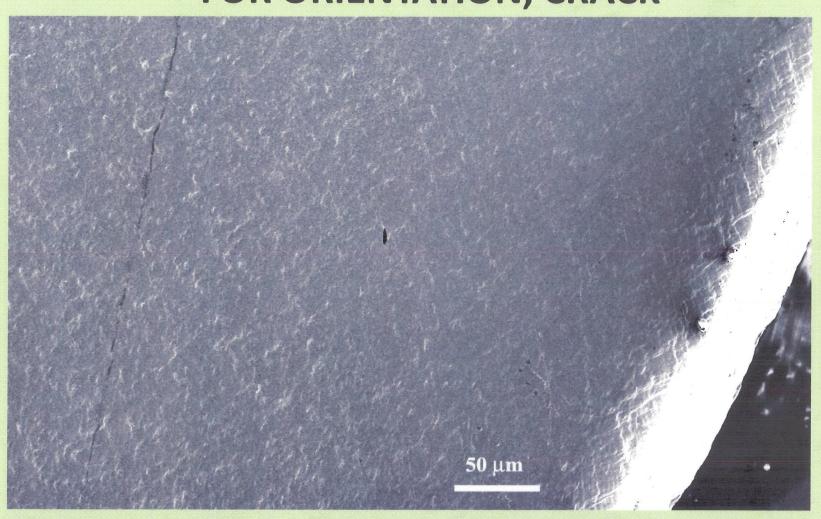


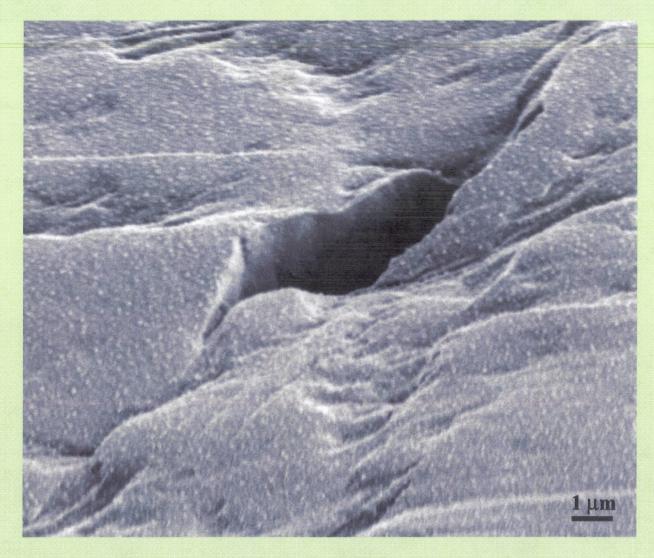
#### SURFACE DIPS WHERE Cu IS DE-NANOTWINNED



**FATIGUED AT 450 MPa MAXIMUM STRESS** 

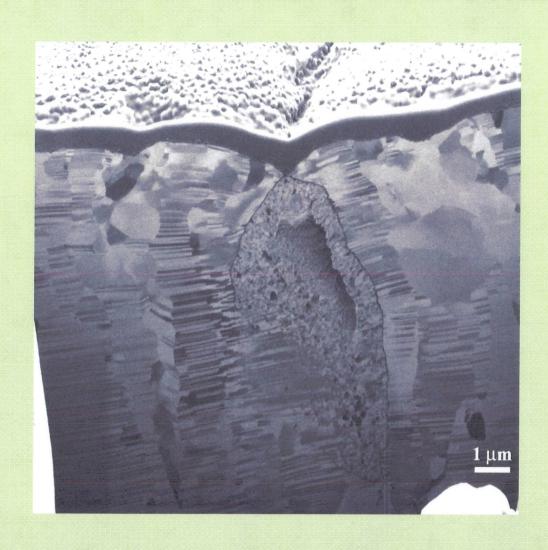
# TWO SETS OF PARALLEL SURFACE DEPRESSIONS ON FATIGUED SAMPLE; NOTE SAMPLE EDGE FOR ORIENTATION, CRACK





CRACK AT INTERSECTION OF TWO
SURFACE DEPRESSIONS IN
FATIGUED Cu

### HOLE BELOW SURFACE, NOTE DIP AT SURFACE FATIGUED AT 450 MPa MAX STRESS

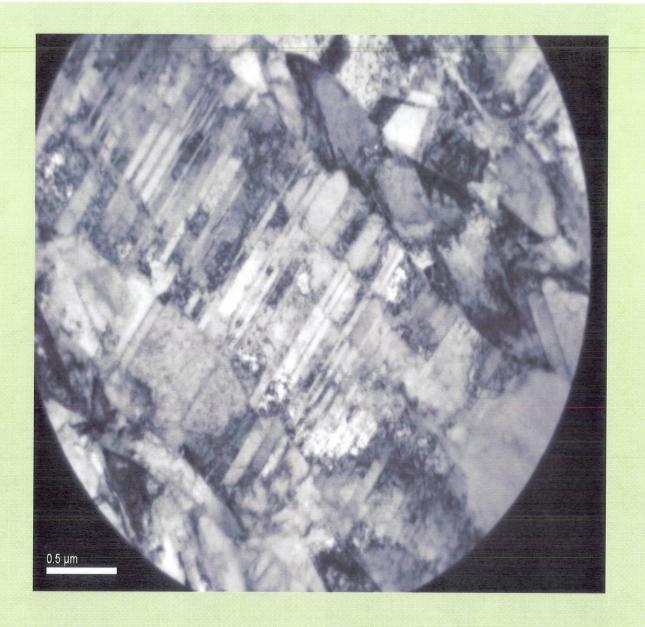


### TRANSVERSE FIB CUT THROUGH SURFACE CRACK IN FATIGUED COPPER



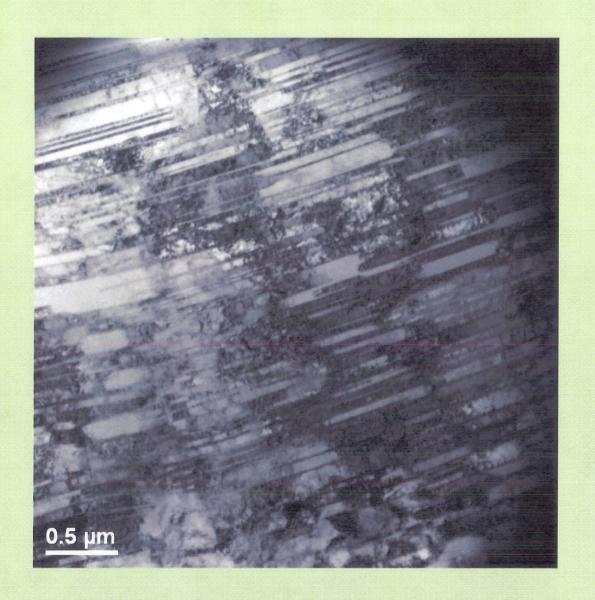
DISLOCATION
BUILD UP AT
INTERFACES
BETWEEN
DIFFERENT MODES
OF DEFORMATION

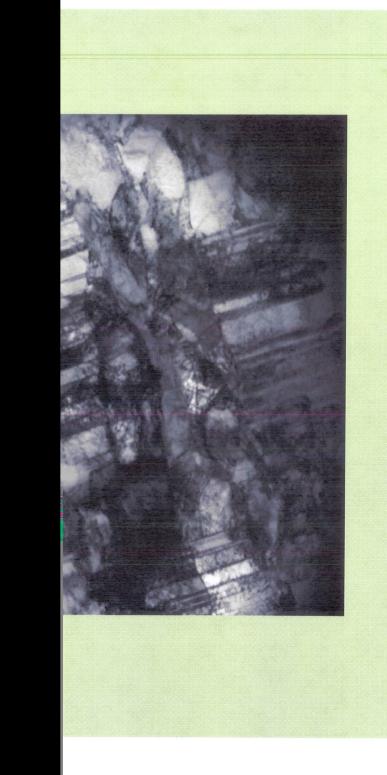
Fatigued to failure at 450 MPa max stress



DISLOCATION
BUILD UP AT
COLUMN
BOUNDARIES

Sample fatigued at 450 MPa





#### OF DEFORMATION ON HARDNESS

#### HARDNESS (GPa)

sed 1.8-1.9

sed to 3840 MPa 1.8

ion fatigue, 5000 cycles

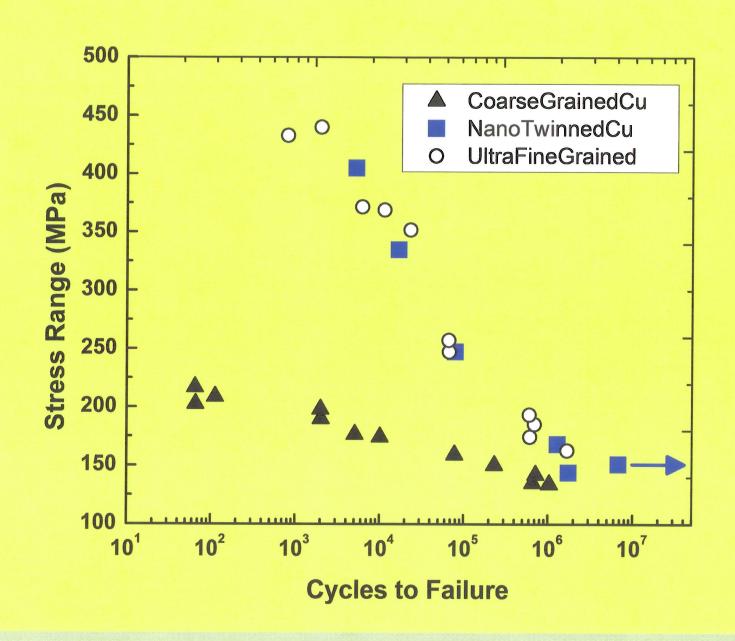
-56 MPa 1.8

nsion-tension

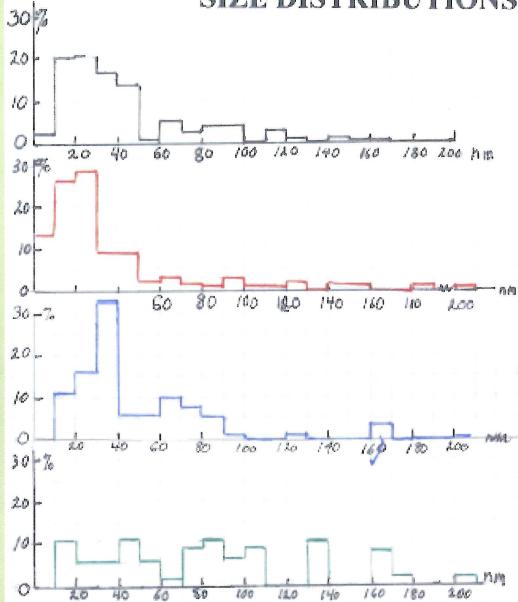
37 MPa, 20,000 cycles 1.7-1.8

nsion-tension

45 MPa, 5195 cycles 1.7







As received, median TB spacing =  $\sim 35^{\circ}$  nm

Compressed, -25% strain, median spacing ~ 25<sup>+</sup> nm

Fatigued 450 MPa max stress median spacing ~ 35<sup>+</sup> nm

Fatigued 450 MPa, near crack median spacing ~ 50 nm

#### **SUMMARY**

Nanotwinned Cu combines strength and stability

However, especially under fatigue conditions, de-twinning can occur, leading to deformation incompatibilities and crack nucleation